

 **Sughrue**

SUGHRUE MION, PLLC

February 14, 2002

BOX PATENT APPLICATION

Commissioner for Patents

Washington, D.C. 20231

Re: Application of Tsutomu SHOKI and Morio HOSOYA
REFLECTION TYPE MASK BLANK FOR EUV EXPOSURE AND REFLECTION
TYPE MASK FOR EUV EXPOSURE AS WELL AS METHOD OF PRODUCING THE
MASK

Assignee: HOYA CORPORATION

Our Ref. Q68554

Dear Sir:

Attached hereto is the application identified above comprising twenty-nine (29) sheets of the specification, including the claims and abstract, three (3) sheets of drawings, executed Assignment and PTO 1595 form, and executed Declaration and Power of Attorney.

The Government filing fee is calculated as follows:

Total claims	8 - 20	=		x	\$18.00	=	\$0.00
Independent claims	2 - 3	=		x	\$84.00	=	\$0.00
Base Fee							\$740.00
Multiple Dependent Claim Fee							\$280.00
TOTAL FILING FEE							\$1020.00
Recordation of Assignment							\$40.00
TOTAL FEE							\$1060.00

Checks for the statutory filing fee of \$1020.00 and Assignment recordation fee of \$40.00 are attached. You are also directed and authorized to charge or credit any difference or overpayment to Deposit Account No. 19-4880. The Commissioner is hereby authorized to charge any fees under 37 C.F.R. §§ 1.16 and 1.17 and any petitions for extension of time under 37 C.F.R. § 1.136 which may be required during the entire pendency of the application to Deposit Account No. 19-4880. A duplicate copy of this transmittal letter is attached.

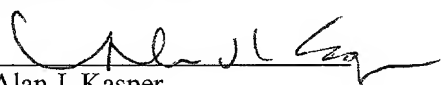
Priority is claimed from:

<u>Country</u>	<u>Application No</u>	<u>Filing Date</u>
Japan	37034/2001	February 14, 2001

The priority document will be filed at a later date.

Respectfully submitted,
SUGHRUE MION, PLLC

Attorneys for Applicant

By: 
Alan J. Kasper
Registration No. 25,426

AJK/amt